

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Initial Patent Examination

Division

Jack O. Chu et al.

09/838,892

Confirmation No.: 166

: Date: September 17, 2001

Filed:

Serial No.:

April 20, 2001

For: Epitaxial and Polycrystalline Growth of $Si_{1-x-y}Ge_xC_y$ and $Si_{1-y}C_y$ Alloy Layers

on Si by UHV-CVD

ASSISTANT COMMISSIONER FOR PATENTS Initial Patent Examination Division WASHINGTON, D.C. 20231

PETITION AND FEE FOR EXTENSION OF TIME (37 CFR 1.136(a))

- This is a petition for an extension of time to respond to the Notice to File Missing Parts of Nonprovisional Application mailed on <u>june 15, 2001</u> for a period of one (1) month from <u>August 15, 2001</u>, to and including <u>September 17, 2001</u>.
- 2. Applicant is other than a small entity.
- 3. Extension:

Month(s)		Estimated fee for other than Small Entity	
[X]	one month	<u>\$</u>	110.00
[]	two months	\$	390.00
[]	three months	\$	890.00
[]	four months	\$	1,390.00
		FEE: S	110.00

- 4. A Response
 - [X] is filed herewith
 - [] has been filed.
- 5. Fee payment
 - [X] Charge the required fee to Deposit Account No. $\underline{09-0468}$ and charge any additional fee required or credit for any excess fee paid to that account. A duplicate of this petition is attached.

Respectfully submitted,

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Intellectual Property Law Department

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IBM Corporation

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